

Zeiss Microscopy Technology and Complete Correlative Workflow

Zeiss, as microscopy technology leader, provides the unique complete imaging solution ranging from light, confocal, electron, ion and Xray modalities with a complete and straightforward correlative workflow.

An overview of different technologies will be presented with a special focus on X-Rray microscopy.

As X-Ray Microscopy is extended from the Synchrotron community to the laboratory, correlation to other imaging techniques is vital for many reasons. Partly due to the need to show where the technique fits in the landscape of multi length scale imaging and partly to show the efficacy of the application by correlating similar imaging modalities. We will show through various applications from the fields of Biology and Materials how X-Ray microscopy complements existing technology, not replacing any technique, but adding further information to gain a deeper understanding of the scientific application

Wednesday July 19th CNR NANOTEC c/o Campus Ecotekne Via Monteroni – Lecce Aula Seminari – pal. G, Piano Terra

Start time 10:00 a.m.

Agenda

10:00 - 10:15	Welcome CNR Nanotec	Giuseppe Gigli, CNR Nanotec
10:15 - 10:30	Zeiss Microscopy Company Profile	Giulio Lamedica, Carl Zeiss SpA
10:30 - 11:00	Electron and Ion beam technology	Francesco Biancardi, Carl Zeiss SpA
11:00 - 11:30	LSM Airyscan and Superresolution	Alessandro Cometta, Carl Zeiss SpA
11:30 - 12:30	X-Ray Microscopy as a correlative imaging technique	Lars- Oliver Kautschor, Carl Zeiss Microscopy GmbH

Seats availability is limited. Please reserve your seat writing your contact details (first name, last name, position, institute, telephone, e-mail) to: marketing.czi@zeiss.com



